

PTO/SB/08A (08-03)

Substitute for form 1449A/PTO

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

(use as many sheets as necessary)

Sheet	1	of	2	Attorney Docket Number	A8443/T52300
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Complete if Known

Application Number	10/757,771
Filing Date	January 14, 2004
First Named Inventor	Yuan, Zheng
Art Unit	Not yet known 2923
Examiner Name	Not yet known William M. Branstetter

U.S. PATENT DOCUMENTS+

Examiner Initials*	Cite No. ¹	Document Number Number Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
QVB	A1	US-5,660,472	08-26-1997	Peuse et al.	X
QVB	A2	US-5,939,763	08-17-1999	Hao et al.	
QVB	A3	US-6,150,286	11-21-2000	Sun et al.	
QVB	A4	US-6,150,209	11-21-2000	Sun et al.	
QVB	A5	US-6,171,901 B1	01-09-2001	Blair et al.	
QVB	A6	US-6,184,155 B1	02-06-2001	Yu et al.	
QVB	A7	US-6,190,973 B1	02-20-2001	Berg et al.	
QVB	A8	US-6,245,689 B1	08-12-2001	Hao et al.	
QVB	A9	US-6,248,628 B1	06-19-2001	Halliyal et al.	
QVB	A10	US-2002/0052128 A1	05-02-2002	Yu et al.	
QVB	A11	US-2002/0102358 A1	08-01-2002	Das et al.	
QVB	A12	US-6,489,254	12-03-2002	Kelkar et al.	
QVB	A13	US-6,512,264 B1	01-28-2003	Ogle, Jr. et al.	
QVB	A14	US-2003/0057432 A1	03-27-2003	Gardner et al.	
QVB	A15	US-6,541,367 B1	04-01-2003	Mandal	
QVB	A16	US-2003/0071304 A1	04-17-2003	Ogle, Jr. et al.	
QVB	A17	US-2003/0073290 A1	04-17-2003	Ramkumar et al.	
QVB	A18	US-2003/0140851 A1	07-31-2003	Lund	X

FOREIGN PATENT DOCUMENTS

Examiner Initials*	Cite No. ¹	Foreign Patent Document			Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ⁶
		Country Code ³	Number ⁴	Kind Code ⁵ (if known)				
QVB	B1	TW	479315		03-11-2002			<input type="checkbox"/>
	B2							<input type="checkbox"/>

Examiner
Signature

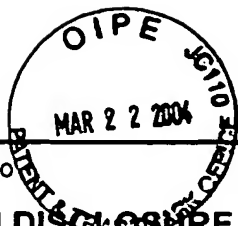
William M. Branstetter

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Considered

26 SEP 05

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				Examiner Name	Not yet known William M. Bruneau
Sheet	2	of	2	Attorney Docket Number	A8443/T52300

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials *	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
W/B	C1	BAKER, F. et al. "STI TEOS Densification for Furnaces and RTP Tools" 1999 IEEE/SEMI Advanced Semiconductor Manufacturing Conference, 1999, pp. 394-399.	
W/B	C2	Applied Materials Website Printout: "SACVD (Sub-Atmospheric Chemical Vapor Deposition)" from www.appliedmaterials.com/products/sacvd.html, printed 06/20/2003.	
	C3		

Examiner Signature	<i>William M. Bruneau</i>	Date Considered	26 SEP 05
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